

Overview Components Vs monocrystalline silicon Deposition methods Upgraded metallurgical-grade silicon Potential applications Novel ideas Manufacturers At the component level, polysilicon has long been used as the conducting gate material in MOSFET and CMOS processing technologies. For these technologies it is deposited using low-pressure chemical-vapour deposition (LPCVD) reactors at high temperatures and is usually heavily doped n-type or p-type. More recently, intrinsic and doped polysilicon is being used in large-area electronics

Polycrystalline silicon is a multicrystalline form of silicon with high purity and used to make solar photovoltaic cells. How are polycrystalline silicon cells produced? Polycrystalline silicon (also called: polysilicon, poly crystal, poly-Si or also: ...

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